



Multimedia Available: Applied Materials Revolutionizes Dielectric Etch Productivity with New Producer Etch System

July 2, 2003

--(BUSINESS WIRE)--

Applied Materials, Inc. revolutionizes dielectric etch productivity with its new Producer(R) Etch system that delivers up to twice the throughput of competitive systems. The Producer Etch also significantly improves capital costs for high-volume chip manufacturing.

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